# **Transport and noise in organic FETs**





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## Organic field effect transistors

	Semiconductor	$\left( \operatorname{CHIZ}_{/} \operatorname{vs} \right)$	
	Rubrene (air, PMMA)	1.5-20	1.5-20
<i>₩</i>	P5	1.5	$10^{8}$
	P5 (PVP-CP)	2.9-3.0	$10^{5}$
V <sub>GS</sub> > 0 V	P5 $(AI_2O_3)$	0.06-0.1	$\sim 10^6$
V <sub>GS</sub> ‡	P5 (SiN $_x$ )	0.2-0.4	$\sim 10^8$
	P5 (Ta $_2O_5$ )	0.24	$10^{4}$
*****	$P5 (Gd_2O_3)$	0.1	$10^{3}$
****	P5 TiO2+P $\alpha$ MS	0.8	$10^{4}$
	P5 (BZT or BST)	0.32-0.60	$\sim 10^{5}$
V <sub>DS</sub> > 0 V	P5-precursor	0.01-0.2	$\sim 10^{5}$
	P5-precursor	0.89	$\sim 10^{7}$
	$Me_4$ -P5	0.3	$10^{3}$ -10
	P5-TIPSA	0.17	$\sim 10^{5}$
	6T	0.002	
Organic Semiconductor P-Channel (N-Type) Operation	8T	0.33	
p- and n-channel thin-film transistor operation	DH-6T	0.05	$10^{3}$
	DH-4T	0.06	$10^{6}$
	$Me_2 ext{-}6T$	0.02	
	Et-6T	0.03-0.05	$> 10^{5}$
$s \longrightarrow s$ bis-BDT $GT: n = 1$ GT: n = 2 P5-TIPSA	Bis-BDT	0.04	
and	Bis-TDT	0.05	$\sim 10^{\circ}$
bis-TDT	DPh-BDX	0.01-2.0	$10^3 \rightarrow 1$
	DH-PTTP	0.09	$10^{5}$
DPh-BDX X = S, Se, Te Et-6T	DH-PPTPP	0.02	$10^{4}$
$c_{10}H_{21}$ $c_{3}$ $c_{1}$ $c_{3}$ $c_{1}$ $c_{3}$ $c_{10}H_{21}$ $c_{10}H_{13}$ $c_{10}H_{$	$Dec\operatorname{-}(TPhT)_2\operatorname{-}Dec$	0.4	$10^{5}$
Dec-(TPhT) <sub>2</sub> -Dec DH-PTTP	DH-FITTFI	0.1	$10^{4}$ -10
R-CCCCC: PR CoH13-CD-CD-S-CD-CoH13	ADT	0.1	
ATD: $R = H$ ATD-TIPSA: $R = SEE_3$ DH-PPTPP	PcCu	0.02-0.1	$\sim 10^3$
Company Contraction Contraction	DT-TTF	1.4	$\sim 10^3$
CITIN CLINIC DH-FITTFI	$PcCuTa_2O_5$	0.01	$\sim 10^{2}$
GO HA STREES	Bis-BDX	0.17-2.0	$  10^{\circ} - 10$
Rubrene PcCu DT-TTF	OFET performance of m	nolecular p-cl	nannel se
structures of molecular p-channel organic semiconductors	conductors		
	Antonio Facchetti, materialstoday 10,3 (20)		
	28		

		Semiconductor	(cm2/Vs)	lon/loff	
Ļ	↓ v <sub>ps</sub>	Rubrene (air, PMMA)	1.5-20	1.5-20	
	⁄∓ ·	P5	1.5	$10^{8}$	
		P5 (PVP-CP)	2.9-3.0	$10^{5}$	
V <sub>GS</sub> > 0 V	V <sub>GS</sub> < 0 V	$P5\;(AI_2O_3)$	0.06-0.1	$\sim 10^6$	
	los ≠	P5 (SiN $_x$ )	0.2-0.4	$\sim 10^8$	
	$P5~(Ta_2O_5)$	0.24	$10^4$		
	$P5~(Gd_2O_3)$	0.1	$10^{3}$		
++++		P5 TiO2+P $\alpha$ MS	0.8	$10^4$	
:	:	P5 (BZT or BST)	0.32-0.60	$\sim 10^5$	
V <sub>DS</sub> > 0 V	V <sub>DS</sub> < 0 V	P5-precursor	0.01-0.2	$\sim 10^5$	
	P5-precursor	0.89	$\sim 10^7$		
	Ĩ`®→® <sup>1</sup>	$Me_4$ -P5	0.3	$10^{3}$ - $10^{5}$	
		P5-TIPSA	0.17	$\sim 10^5$	
		6T	0.002		
Organic Semiconductor	N-Channel (N-Type) Operation	8T	0.33		
p- and n-channel thin-	film transistor operation	DH-6T	0.05	$10^{3}$	
	Me Si/-Pr	DH-4T	0.06	$10^{6}$	
CLILL Me CLI P5 Me		$Me_2 ext{-}6T$	0.02		
and the second		Et-6T	0.03-0.05	$> 10^5$	
bis-BDT	GT : n = 1 GT : n = 2 P5-TIPSA	Bis-BDT	0.04		
شې شې شو د شې شو شو		Bis-TDT	0.05	$\sim 10^8$	
bis-TDT	n = 4: DH-4T	DPh-BDX	0.01-2.0	$10^3 \rightarrow 10^7$	
	n = 6 : DH-6T	DH-PTTP	0.09	$10^{5}$	
DPh-BDX X = S, Se, Te	Et-6T	DH-PPTPP	0.02	$10^{4}$	
C10H21 S CILS	C10H21 C0H13 CIUS STITC-H.	$Dec\operatorname{-}(TPhT)_2\operatorname{-}Dec$	0.4	$10^{5}$	
Dec-(TPhT) <sub>2</sub> -Dec DH-PTTP	DH-FITTFI	0.1	$10^4 - 10^5$		
R-COCCIS-R C	HIS CO CO S CO CO COHIS	ADT	0.1		
ATD : $R = H$ ATD-TIPSA : $R =siEt_s$	DH-PPTPP		0.02-0.1	$\sim 10^{5}$	
		DT-TTF	1.4	$\sim 10^{5}$	
atto attitudo	DH-FITTFI	$PcCuTa_2O_5$	0.01	$\sim 10^4$	
GG YY	IHC.	Bis-BDX	0.17-2.0	$10^{\circ}-10'$	
Rubrene PcCu	DT-TTF	OFET performance of molecular p-channel semi-			
structures of molecular	r p-channel organic semiconductors	conductors			
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#### Tight binding model for HOMO, LUMO transport



fragment orbital approach with self-consistent charge densityfunctional based tight-binding (SCC-DFTB) method (Elstner1998,Porezag1995,Seifert1996)

### Thermoelectric properties

Temperature difference at right:  $T_r = T + \Delta T/2$  and left lead:  $T_r = T - \Delta T/2$ 

> particle current  $J = L^{11}V + L^{12}\Delta T$ heat current  $J_q = L^{21}V + L^{22}\Delta T$







